

Vault CP&C 20R3 Release Impact Assessment

The Release Impact Assessment (RIA) documents the new capabilities introduced in Vault Consumer Products & Chemical (CP&C) applications in 20R3 that may affect a customer's vault. We release a version of the RIA in advance of the general release. On November 2nd, the CP&C Validation Impact Assessment, which contains validation information for new features in 20R3, will be available in your VeevaDocs vault. Refer to the Enablement and Default Impact for each feature to determine the visibility and configuration requirements. On October 26th, the 20R3 Release Notes will be available. Refer to the release notes for additional details about each feature and data model changes in your vault. Refer to the Vault 20R3 Release Impact Assessment for validation information for the Vault Platform.

Revision Date: 26 Oct 2020

This feature list is subject to change prior to the 20R3 release. We will begin tracking changes on October 12th, 2020.

Feature:	Name of the feature introduced in 20R3				
GxP Risk:	GxP risk analysis takes into account data integrity, security, and confidentiality assuming the feature is turned on (either automatically or via configuration). Veeva performs validation testing on all High and Medium GxP risk items.				
High	May affect security, patient confidentiality, application areas that support GxP functions (audit trails, eSignature, etc.) or otleRES controls data				
Medium	May affect core application functions (workflows, revision history, etc.)				
Low	May affect metadata/notifications				
N/A	The feature is a minor UI enhancement and not a functional change. The feature has no validation impact.				
Enablement Setting: Indicates whether the feature is available automatically, requires configuration by an Admin (an Admin area more complex setup), or must be enabled by contacting Veeva Support. Note that in some cases, an Autodependent on another feature that must be enabled or configured. In other cases, individual users (not Admin area more complex setup), for example, with new Reporting capabilities that require creation of a new report.					
Default Impact:	Impact to business users and processes at Day 1 if no configuration occurs				
Visible to All Users	Automatically on and visible to both Admins and end users				
Visible to Admins Only	Only visible to Admins, or it requires configuration by an Admin before it is available to end users				
None	None Not visible in Vault unless enabled by Support				

CP&C	Application	Feature Name	GxP Risk	Enablement	Default Impact	Description
	QualityOne	QualityOne Mobile for iPadOS	High	Configuration	Visible to Admins Only	An iPadOS application that supports Offline mode, allowing users to perform an audit checklist on an iPad that has been authored in Vault.
	QualityOne	Training Management Phase 2	High	Configuration		This feature adds enhancements to QualityOne Training Management including Instructor-Led Training, Multi-Document Training Requirements, and improvements to Training Assignments.
	QualityOne	QualityOne Data Model Improvements	Medium	Auto-on	Visible to Admins Only	This feature adds new objects in QualityOne to transition away from Quality Event object types.
	QualityOne	Incident Management Standard Object Model	Low	Auto-on	1	This feature adds new Incident Management objects to QualityOne.
	QualityOne	QualityOne Mobile for iOS Enhancements	Low	Auto-on	Visible to All Users	This feature enhances the user experience for QualityOne Mobile iOS users.
	Veeva Claims	Pack Copy Hierarchy Viewer & Navigator	Medium	Configuration	Visible to Admins Only	This feature allows users to view and navigate a packaging copy hierarchy.
	Veeva Claims	Substantiation Object	Low	Configuration	1	This feature adds a Substantiation object to Veeva Claims vaults.

Change Log

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Date	Change	Impact	
26 Oct 2020	Added links to the 20R3 release notes.	The RIA now includes links to the 20R3 release notes.	
05 Oct 2020	Initial RIA Published	N/A	